

Supplementary Information for
**Coassembly System of Aromatic Donor and Acceptor: Charge Transfer,
Electric Bistability, and Photoconductivity**

**Jia Luo,^a Linfeng Chen,^a Jie-Yu Wang,^b Ting Lei,^b Li-Yi Li,^b Jian Pei,^{*,b} and
Yanlin Song^{*,a}**

*Beijing National Laboratory for Molecular Sciences (BNLMS), Key Laboratory of Organic Solid,
Laboratory of New Materials, Institute of Chemistry, The Chinese Academy of Sciences, Beijing, 100190
(China); ylsong@iccas.ac.cn*

*Beijing National Laboratory for Molecular Sciences, the Key Laboratory of Bioorganic Chemistry and
Molecular Engineering of the Ministry of Education, College of Chemistry, Peking University, Beijing
10087 (China); jianpei@pku.edu.cn*

Experimental section

General Procedures. Compounds **Tr** and **TrO₃** were synthesized followed the procedure in our previous report.¹ Absorption spectra were recorded on a PerkinElmer Lambda 35 UV-vis Spectrometer. Photoluminescent (PL) spectra were carried out on a PerkinElmer LS55 Luminescence Spectrometer. Cyclic voltammetry was performed using BASI Epsilon workstation and measurements were carried out in acetonitrile containing 0.1 M *n*-Bu₄NPF₆ as a supporting electrolyte. Carbon electrode was used as a working electrode and a platinum wire as a counter electrode; all potentials were recorded versus Ag/AgCl as the reference electrode. The scan rate was 50 mV·s⁻¹. Optical microscopy was conducted with an Olympus BX-51 microscope. Scanning electron microscopy (SEM) images were obtained with a cold field emission scanning electron microscope (Hitachi S4800) operated at an accelerating voltage of 1.0 kV. Atomic force microscopy (AFM) studies were performed with a Nanoscope IIIa microscope (Extended Multimode, Digital Instruments, Santa Barbara, CA). All experiments were carried out in tapping mode at ambient temperature. Scanning Tunneling Microscopy (STM) studies were performed with a Solver P47 apparatus under ambient conditions. The STM tips were made of electrochemically etched tungsten.

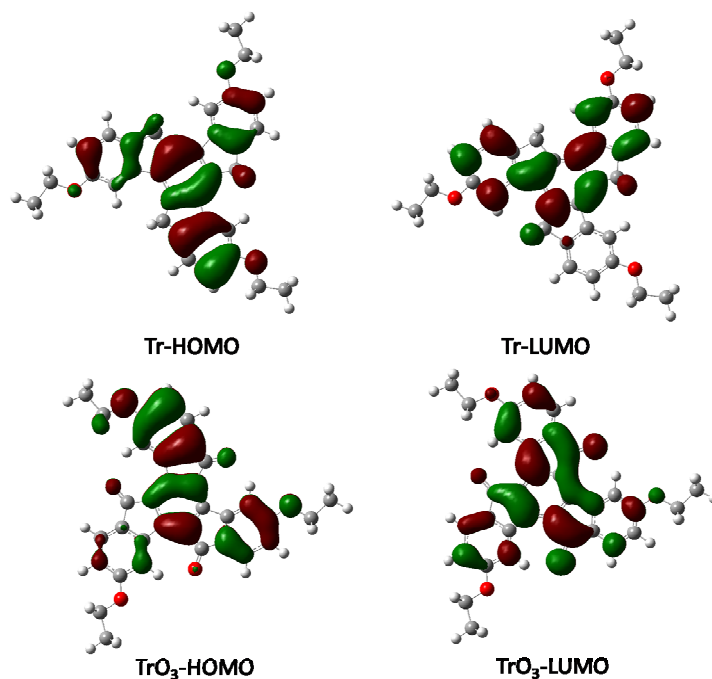


Figure S1. HOMO and LUMO distribution of **Tr** and **TrO₃** calculated by DFT using B3LYP/6-311+G (d, p)//B3LYP/6-31G (d) level. All the hexyl groups were replaced with ethyl groups for simplicity.

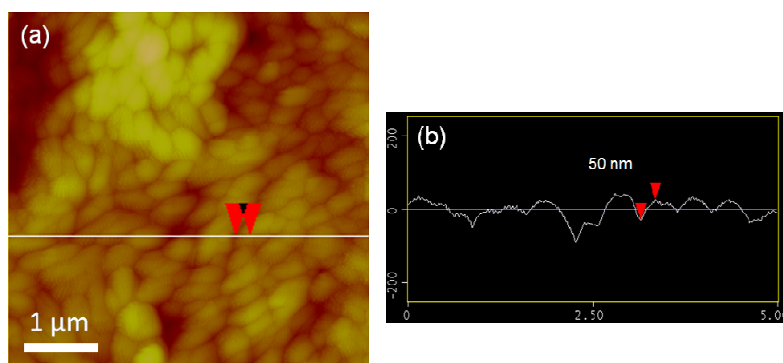


Figure S2. AFM height images (a) and cross section (b) of thin film of **1 Tr:TrO₃** (1:1).

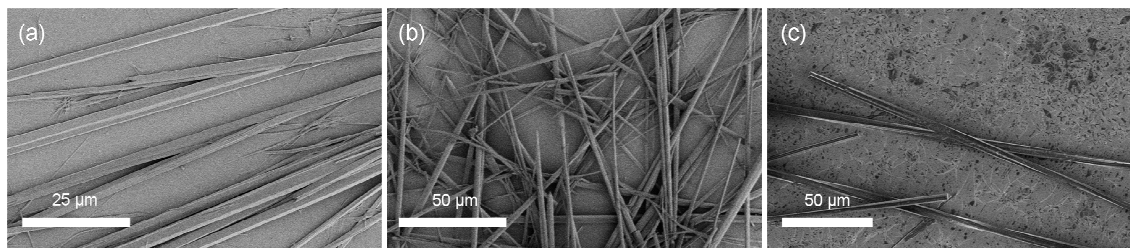


Figure S3. Scanning Electron Microscopy (SEM) images of self-assembled (a) **Tr**; (b) **TrO₃** and (c) **Tr:TrO₃** in hexane.

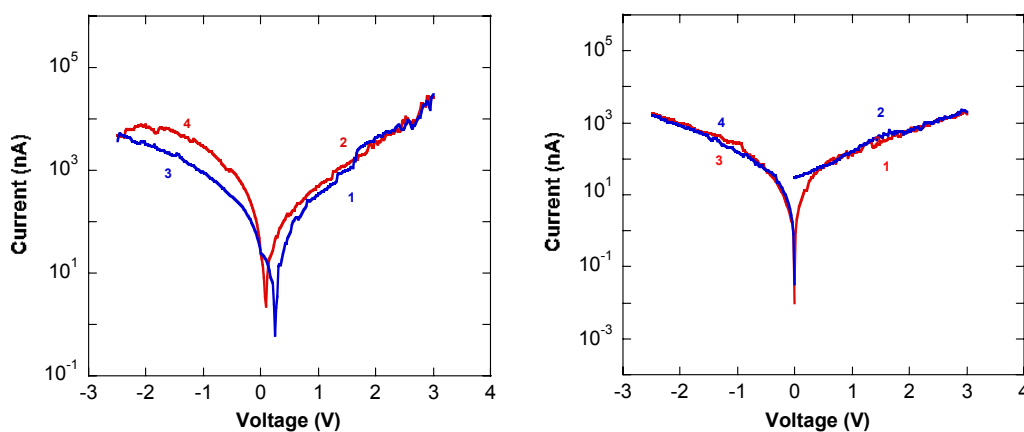


Figure S4. *I-V* characteristics of control devices with the structure ITO/**Tr** or **TrO₃**/Al. The results suggest that no current transition from low to high level happen in single component. The numbers on the curves correspond to the scanning order.

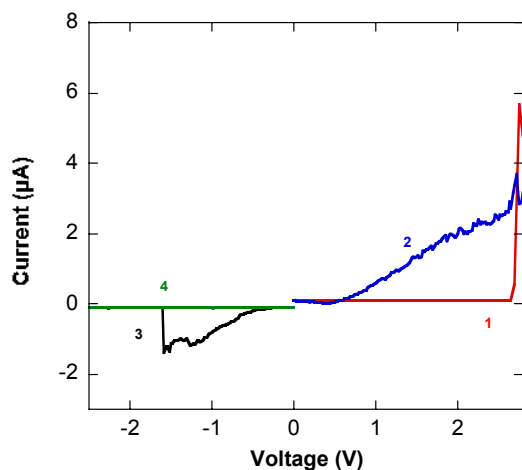


Figure S5. *I-V* characteristics of device with the double-layer structure ITO/ TrO_3 /Tr/Al. The results suggest that similar flash memory effect to device fabricated by $\text{Tr}:\text{TrO}_3$ (1:1). The number on the curves corresponded to the scanning order.

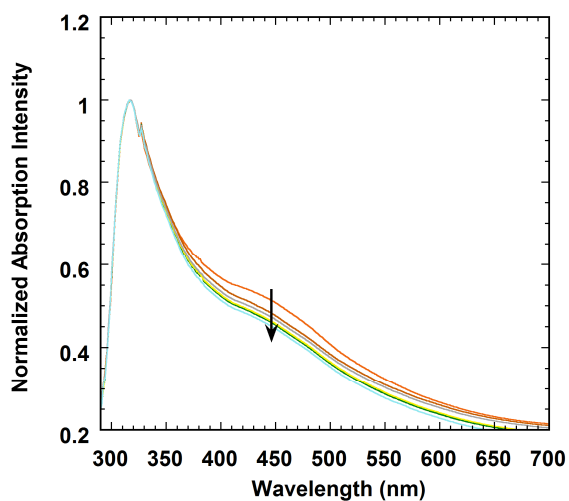


Figure S6. UV-vis absorption spectra of $\text{Tr}:\text{TrO}_3$ film by applying a bias of -2.5 V after the film device was turned “On” by a 3 V bias. The CT transition can be erased by such a manner. The time interval is 10 s.

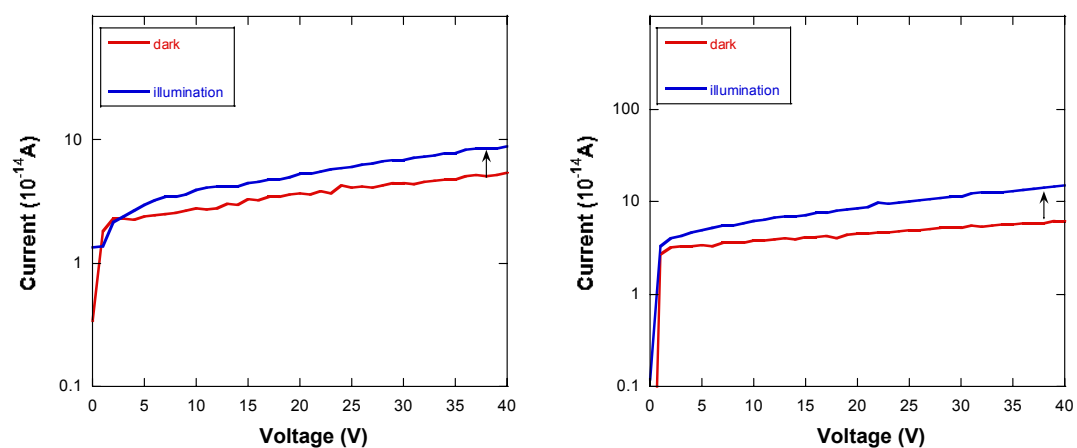


Figure S7. *I-V* characteristics of single wires of (a) **Tr** and (b) **TrO₃** under dark and illumination.